WHAT WE CLAIM ARE:

- 1. A method of manufacturing a liquid crystal display, comprising the steps of:
- (a) heating a liquid crystal display substrate and forming a main wiring layer of Al or Al alloy thereon, in which grains are grown in the formed
 5 main wiring layer and the substrate is heated to such a temperature as the main wiring layer has an irregular surface having an average roughness Ra of 3 nm or larger;
 - (b) forming a heat resistant cover metal layer on the main wiring layer to form a laminated metal layer; and
- 10 (c) heating the substrate and forming an insulating film on the laminated metal layer by CVD.
 - 2. The method according to claim 1, wherein said step (a) grows grains in the main wiring layer in vertical direction.

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- 3. The method according to claim 1, wherein said step (a) heats the substrate to a temperature of 175 °C to 400 °C.
- The method according to claim 3, wherein said step (a) heats the substrate in
 a heating chamber of a sputtering system, and transports the substrate into a
 sputtering chamber to form the main wiring layer by sputtering.
- 5. The method according to claim 1, wherein the heat resistant cover metal layer includes one of a refractory metal layer, a refractory metal alloy layer and a nitrogen-containing refractory metal layer.

- 6. The method according to claim 1, wherein said step (b) forms a metal layer containing refractory metal on the main wiring layer by sputtering.
- 5 7. The method according to claim 6, wherein said step (b) stacks a nitrogencontaining refractory metal layer and a refractory metal layer on the main wiring layer.
 - 8. A method of manufacturing a liquid crystal display, comprising the steps of:
- (a) forming a main wiring layer of Al or Al alloy on a liquid crystal display substrate;
 - (b) exposing the substrate to an atmosphere containing oxygen to naturally oxidize a surface of the main wiring layer;
- (c) forming a heat resistant cover metal layer on the main wiring

 15 layer to form a laminated metal layer; and
 - (d) heating the substrate and forming an insulating film on the laminated metal layer by CVD.
- The method according to claim 8, wherein the heat resistant cover metal
 layer includes one of a refractory metal layer, a refractory metal alloy layer and a nitrogen-containing refractory metal layer.
 - 10. A liquid crystal display comprising:
 - a liquid crystal display substrate;
- a main wiring layer made of Al or Al alloy and formed on said

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a protective layer containing refractory metal and formed on the main wiring layer,

wherein an upper surface of said main wiring layer has an average roughness of 3 nm or larger.

- 11. The liquid crystal display according to claim 10, wherein said main wiring layer forms gate wiring lines and storage capacitor wiring lines, and the liquid crystal display further comprises:
- a gate insulating film covering said protective layer;
 a semiconductor layer formed on said gate insulating film;
 an insulating layer covering a region above said semiconductor layer; and

pixel electrodes formed on said insulating layer.

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12. The liquid crystal display according to claim 10, further comprising:

an opposing substrate; and

a liquid crystal layer sandwiched between said liquid crystal display substrate and said opposing substrate.

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- 13. A liquid crystal display comprising:
 - a liquid crystal display substrate; and
- a main wiring layer made of Al or Al alloy and formed on said main wiring layer,
- wherein an upper surface of said main wiring layer is formed with a

natural oxide layer.

main wiring layer.

14. The liquid crystal display according to claim 13, wherein a stress of said main wiring layer is 150 MPa or smaller.

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- 15. The liquid crystal display according to claim 13, further comprising:
 a protective layer containing refractory metal and formed on the
- 10 16. The liquid crystal display according to claim 15, wherein said main wiring layer forms gate wiring lines and storage capacitor wiring lines, and the liquid crystal display further comprises:

a gate insulating film covering said protective layer;

a semiconductor layer formed on said gate insulating film;

an insulating layer covering a region above said semiconductor layer; and

pixel electrodes formed on said insulating layer.

- 17. The liquid crystal display according to claim 16, further comprising:
- 20 an opposing substrate; and

a liquid crystal layer sandwiched between said liquid crystal display substrate and said opposing substrate.